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Serial No. 10/519,242	Filing Date December 22, 2004	Examiner WU, Ives J.	Group Art Unit 1713	
P 1 6 2005 W	TON FOR ANTIREFLECTIVE CO	DATING AND METHOD FOI	R FORMING SAME	
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(21)Application number: 09-292051 (71)Applicant: ASAHI GLASS CO LTD

(22) Date of filing: 24.10.1997 (72) Inventor: YOKOZUKA TOSHISUKE

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## (54) COATING COMPOSITION

## (57)Abstract:

PROBLEM TO BE SOLVED: To obtain a composition which has a low refractive index suitable for antireflecting film on a photoresist surface and can be completely removed by developer during developing of the photoresist by using a fluorine-based polymer containing a specific polymerization unit.

SOLUTION: A fluorine-based polymer to be used contains a polymerization unit represented by -CF2CF(ORfCOOM)- or both the above polymerization unit and a polymerization unit represented by -CF2CFX- (Rf is a linear or branched perfluoroalkylene which may contain an ether oxygen; -COOM includes -COOH, -COOY (Y is a non-substituted or substituted ammonium ion) and -COOH.Z (Z is an amine); and X includes fluorine and chlorine). Number average molecular weight of the fluorine-based polymer is preferably  $1\times103-3\times104$ . A solvent to be used is water, an organic solvent or a mixture of water and an organic solvent.

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